# Symposium Domain Wall Functionality and Engineering in Complex Oxides (SYDW)

jointly organized by the Dielectric Solids Division (DF) the Thin Films Division (DS) the Crystallography Division (KR) the Magnetism Division (MA) the Microprobes Division (MI), and the Low Temperature Physics Division (TT)

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This symposium focuses on present and future developments in the emergent field of domain wall engineering, related functionality and concepts, as well as advanced characterization methods. The goal of the symposium is to discuss the state of the art of the research on magnetic, ferroelectric, and multiferroic domain walls and identify open key questions and important challenges in this rapidly growing field.

# Overview of Invited Talks and Sessions

(Lecture room: H 0105)

## **Invited Talks**

SYDW 1.1	Mon	9:30 - 10:00	H 0105	Domain walls: from conductive paths to technology roadmaps —
				•Gustau Catalan
SYDW 1.2	Mon	10:00-10:30	H 0105	Domain walls and oxygen vacancies - towards reversible control of
				domain wall conductance — • PATRYCJA PARUCH
SYDW 1.3	Mon	10:30 - 11:00	H $0105$	Novel mechanisms of domain-wall formation — •ANDRES CANO
SYDW 1.4	Mon	11:30-12:00	H $0105$	Novel materials at domain walls — •BEATRIZ NOHEDA
SYDW 1.5	Mon	12:00-12:30	H $0105$	Controlling and mapping domain wall behaviour in ferroelectrics
				Michael Campbell, Amit Kumar, Roger Whatmore

### Sessions

Domain Walls
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#### SYDW 1: Symposium on Ferroic Domain Walls

Time: Monday 9:30-12:30

Invited

Domain

Talk		SYDW 1	.1 Mon 9	:30 H 0105	I
walls:	from	conductive	paths to	technology	m

roadmaps — •GUSTAU CATALAN — ICREA-Institucio Catalana de Recerca i Estudis Avançats, Barcelona — ICN2-Institut Catala de Nanociencia i Nanotecnologia, Campus UAB, Bellaterra, Barcelona

In this talk, I would like to give a bird's eye view of the field of domain wall nanoelectronics, starting from some basic physics, through a summary of the state of the art, and finishing with a brief and nonexhaustive discussion of unresolved problems. Topics will include the origin(s) of conductivity in perovskite domain walls, the internal phase diagram of domain walls, the interaction of domain walls with other interfaces, how much do we (not) know about the structure, energy cost and dynamics of domain walls, and some strategies for controlling their nucleation and motion.

Disclaimer: The talk will cover much ground in a short time, and will include many results and ideas that are not mine; important works may be misrepresented or underrepresented. I apologize in advance.

Invited Talk SYDW 1.2 Mon 10:00 H 0105 Domain walls and oxygen vacancies - towards reversible control of domain wall conductance — •PATRYCJA PARUCH — Department of Quantum Matter Physics, University of Geneva, Switzerland

In ferroelectric materials, domain walls separate regions with different polarisation orientation, and can present novel functional properties quite different from those of the parent phase. The extreme localisation of such properties at these intrinsically nanoscale features makes them potentially useful as active components in future miniaturized electronic devices.

Particularly exciting has been the discovery of domain-wall-specific electrical conductivity, shown first in multiferroic BiFeO<sub>3</sub>. I will present our observation of conductance at  $180^{\circ}$  domain walls in the simpler ferroelectric Pb(Zr,Ti)O<sub>3</sub>, using a range of scanned probe microscopy techniques at different time scales.

Our measurements highlight the key role of surface adsorbates and oxygen vacancies, and show how their density and distribution can be modulated to reversibly control domain wall transport. Exploring the conductance of the domain walls under both direct and alternating current regimes, we also address the question of maximum packing density of individual current channels in epitaxial ferroelectric thin films.

Invited Talk SYDW 1.3 Mon 10:30 H 0105 Novel mechanisms of domain-wall formation — •ANDRES CANO — CNRS, Univ. Bordeaux, ICMCB, F-33600 Pessac, France

Domain walls in ferroic materials are inherent interfaces separating different ordered regions. They can exhibit specific properties radically different from those of the corresponding domains. I will discuss two novel (and, achtung!, unrelated) mechanisms for the formation of domain walls in (multi-)ferroics:

- In conventional ferroelectrics like BaTiO<sub>3</sub>, the desirable enhancement of ferroelectricity at metal-oxide interfaces can in fact promote the appearance of ferroelectric domain walls in nanoscale capacitors. I will discuss the various factors that control the physics behind this surprising phenomenon (e.g. interfacial energy vs. ferroelectric stiffness).
- In improper ferroelectrics like the hexagonal RMnO<sub>3</sub> manganites,

Location: H 0105

Monday

I will show that the emergence of multiferroic domain walls (and more complex topological defects) can be rationalized in terms of different residual-symmetry-breaking mechanisms associated to the primary order parameter.

#### Coffee break

Invited Talk SYDW 1.4 Mon 11:30 H 0105 Novel materials at domain walls — •BEATRIZ NOHEDA — Zernike Institute for Advanced Materials, Groningen, The Netherlands

There is a growing need to control and improve the physical responses of useful electronic materials, as well as to induce additional functionalities of significance for applications. Domain wall nanoelectronics has been proposed as a suitable route to achieve such control at the smallest scales. Addressing the domain wall functionalities, in particular those of ferroelastic domain walls, we take advantage not only the intrinsic symmetry breaking that takes place at the wall but also of the strain gradients that are associated to these walls. The possibility to generate periodic arrays of domain walls by self-assembly during epitaxial growth is an added benefit. I will show that, depending of the chosen thin film material, the local stresses that develop locally around ferroelastic domain walls can either trigger local electrochemistry or give rise to atomic arrangements that cannot be obtained by other existing routes, generating novel 2D materials with distinct nanoscale functionalities.

The works presented here are in collaboration with S. Farokhipoor, C.J.M. Daumont, D. Rubi, C. Magén, E. Snoeck, S. Venkatesan, A. Müller, M. Döblinger, C. Scheu, J. Íñiguez, M. Mostovoy and C. de Graaf.

Invited Talk SYDW 1.5 Mon 12:00 H 0105 Controlling and mapping domain wall behaviour in ferroelectrics — •JOHN MARTIN GREGG<sup>1</sup>, JONATHAN WHYTE<sup>1</sup>, RAY-MOND McQUAID<sup>1</sup>, MICHAEL CAMPBELL<sup>1</sup>, AMIT KUMAR<sup>1</sup>, and ROGER WHATMORE<sup>2</sup> — <sup>1</sup>Queens University Belfast, Belfast, Northern Ireland, UK — <sup>2</sup>Imperial College London, London, England

Over the last decade there has been an explosion of interest in sheet conductors, such as surface states in topological insulators [1], LaAlO<sub>3</sub>-SrTiO<sub>3</sub> interfaces [2] and graphene. Recent research has shown that ferroic domain walls constitute another exciting group of 2D conductors, with probably even greater potential than those already known: after all, domain walls have special properties in that they are mobile, can be controllably shunted from point to point, and can be spontaneously created, or made to disappear. Luckily for the research community, the field of domain wall nanoelectronics [3] is still young and there is consequently a great deal left to discover.

In this talk, the extent to which ideas developed in the nanomagnetics community can be adapted to allow domain wall injection [4] and motion control in ferroelectrics, as needed for domain wall-based devices, will be discussed. In addition, results from experiments to determine the fundamental nature of conduction in both boracite and manganite domain walls will be presented.

- [1] H. Zhang et al. Nature Physics 5, 438 (2009)
- [2] A. Ohtomo and H. Y. Hwang, Nature 427, 423 (2004)
- [3] G. Catalan et al. Rev. Mod. Phys. 84 119 (2012)
- [4] J. R. Whyte et al. 26, 293 (2014)